

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :  
Hiroto YUKAWA et al. :  
Serial No. NEW : Attn: APPLICATION BRANCH  
Filed March 29, 2004 : Attorney Docket No. 2004-0499

POSITIVE-WORKING CHEMICAL-  
AMPLIFICATION PHOTORESIST  
COMPOSITION  
**(Rule 1.53(b) Continuation**  
of Serial No. 10/126,673,  
**Filed April 22, 2002)**

**CLAIM OF PRIORITY UNDER 35 USC 119**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY  
FEES FOR THIS PAPER TO DEPARTMENT  
ACCOUNT NO. 23-0975

Sir:

Applicants in the above-entitled application hereby claim the date of priority under the International Convention of Japanese Patent Application No. 10-235453, filed August 21, 1998, as acknowledged in the Declaration of this application.

A certified copy of said Japanese Patent Application is of record in application Serial No. 09/376,304, filed August 18, 1999.

Respectfully submitted,

Hiroto YUKAWA et al.

By Matthew M. Jacob  
Matthew M. Jacob  
Registration No. 25,154  
Attorney for Applicants

MJ/nk  
Washington, D.C. 20006-1021  
Telephone (202) 721-8200  
Facsimile (202) 721-8250  
March 29, 2004